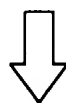
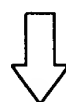
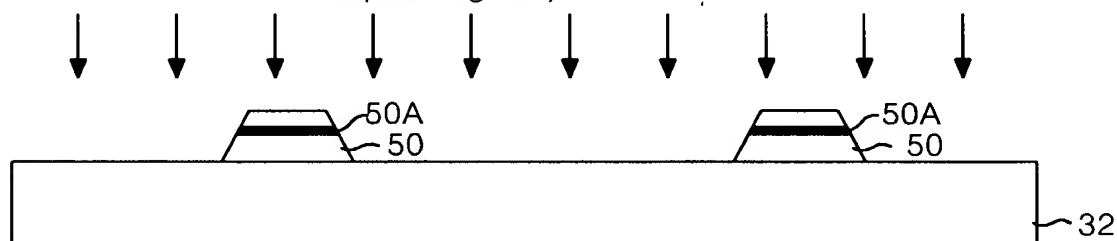


FIG. 4A



depositing Mo, Cr et al.



etching a residual Mo, Cr et al.

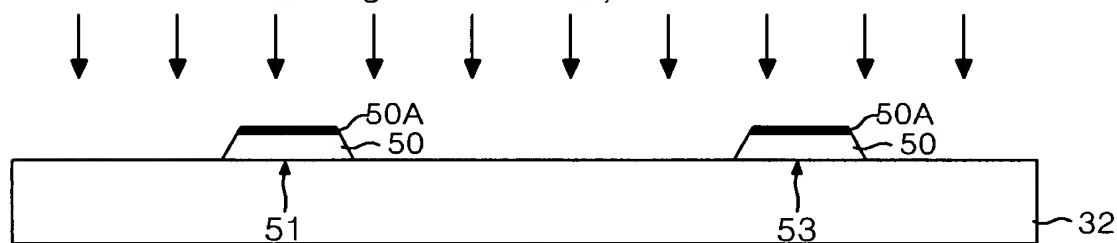


FIG. 4B

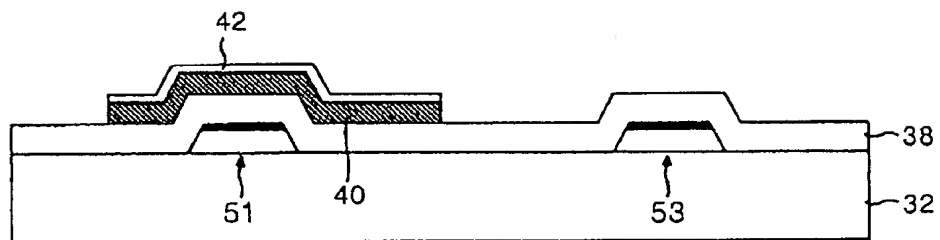


FIG. 4C

